## Amendments to the Claims

This listing of claims will replace all prior versions, and listings of claims in the application.

- (currently amended) A method of testing a semiconductor wafer, the semiconductor wafer having a plurality of die that contain static random access memory (SRAM) arrays, comprising the steps of:
  - (a) coupling an array of probes to the semiconductor wafer; and thereafter
  - (b) applying a voltage difference across a plurality of adjacent bitline pairs and/or worldine pairs a pair of closely spaced wordlines or bitlines of one or more static random access memory (SRAM) arrays of at least one die of the semiconductor wafer, wherein the voltage difference across the pair of closely spaced wordlines or bitlines exceeds a voltage difference that the wordlines or bitlines would experience in normal operation; the voltage being larger than an operational supply voltage for of the one or more SRAM arrays, to thereby induce failure of metal stringers or defect; and
  - identifying whether electrical shorting occurs across said pair of closely spaced wordlines or bitlines.
- (currently amended) The method of claim 1, further comprising the step of simultaneously applying the voltage <u>difference</u> across respective pairs of substantially all parallel bitline pairs and/or wordline pairs of the one or more SRAM arrays.